

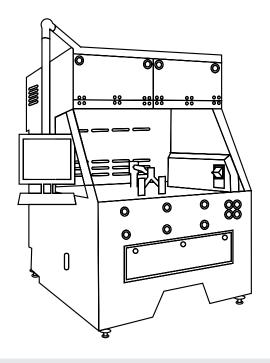
# **Aqueous**

## Semiconductor Solutions

### A Full Range of Materials for Every Fab

Greene Tweed offers a full spectrum of materials to suit the needs of a variety of semiconductor fabs. Greene Tweed has sealing solutions for fabs that use the most advanced technology nodes in the most aggressive operating environments, as well as those requiring less-stringent particle process controls.

Material	Compression Set @ 25% Deflection, %	Hardness, Shore A	Max Service Temperature
Chemraz® 571  Durable compound for wet applications with high sealing loads	70 hours @ 204°C, 35%	80	210°C
Chemraz® 551 Broad chemical resistance at high temperatures	70 hours @ 204°C, 20%	80	316°C



#### **Superior Performance**

- · Minimal extractable ion content
- Exceptional chemical resistance
- Low particle generation
- · High dimensional stability

### **Operational Benefits**

- Superior reliability
- Enhanced repeatability
- · Maximum system uptime
- Lower cost of ownership

#### **Process Applications**

Chemraz® materials can be used in a wide variety of aqueous processes, including:

- Wet etch (acid, base)
- Wet stripping (solvents)
- Wet cleaning (UPDI)
- Wet metal plating
- Chemical Mechanical Planarization (CMP)
- Chemical and deionized (DI) water handling systems

Process	Typical Application Temperatures	Process Environments	Recommended Products
Wafer Preparation	25 – 125°C	UPDI, Pirahna, SC-1, SC-2, O3, HF (49%)	Chemraz <sup>®</sup> 570, 571, 551

Dynamic Applications	Static Applications
<ul><li>Door seals</li><li>Valves (check valves, shutoff valves)</li></ul>	<ul><li>Lid seals</li><li>Drain seals</li><li>Filters and filter housings</li><li>Wet stations (cleaning and etching)</li></ul>

#### **Greene Tweed**

1684 South Broad Street | Lansdale, PA 19446 USA | Phone: (+1) (215) 256-9521 | gtweed.com